

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	0	Van-den-meerakker.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/29 13:40
L2	0	(Van-den-meerakker.in.)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/29 13:41
L3	0	(blaaderen-alfons.in.)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/29 13:41
L4	0	(carlos-maria-van-kats.in.)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/29 13:41
L5	474739	(Van den meerakker.in.)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/29 13:42
L6	31	(meerakker.in.)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/29 13:42
S1	2059	nanowires	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/29 05:55
S2	1272	nanowires and semiconductor	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/28 12:00
S3	245	nanowires and semiconductor and dispersion	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/28 12:00
S4	87	(@ad<="20021118") and nanowires and semiconductor and dispersion	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/29 08:48

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S5	53	(@ad<="20021118") and nanowires and semiconductor and dispersion and etch\$4	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/28 12:02
S6	28	(@ad<="20021118") and nanowires and semiconductor and dispersion and etch\$4 and mask	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/28 12:02
S7	28	(@ad<="20021118") and nanowires and semiconductor and dispersion and etch\$4 and mask	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/28 13:48
S8	0	(@ad<="20021118") and (manufacturing adj nanowires) and semiconductor and dispersion and etch\$4 and mask	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/28 12:16
S9	0	(@ad<="20021118") and (manufactur\$4 with nanowires) and semiconductor and dispersion and etch\$4 and mask	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/28 12:16
S10	145	(@ad<="20021118") and nanowires and semiconductor and etch\$4 and mask	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/28 14:13
S11	75	(@ad<="20021118") and nanowires and semiconductor and etch\$4 and mask and anod\$4	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/28 16:42
S12	16	(@ad<="20021118") and nanowires and semiconductor and etch\$4 and mask and anodically	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/28 16:42
S13	3	(@ad<="20021118") and nanowires and semiconductor and etch\$4 and mask and (anodically with etch\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/28 16:44
S14	35	(@ad<="20021118") and nanowires and semiconductor and etch\$4 and mask and ((anodically or electrochemical\$4) with etch\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/28 17:20

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S15	117	(@ad<="20021118") and (nanowire or nanotube or nanostructure) and semiconductor and etch\$4 and mask and ((anodically or electrochemical\$4) with etch\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/28 17:21
S16	14	("2001/0054709").URPN.	USPAT	OR	ON	2006/03/28 17:31
S17	14	("2001/0054709").URPN.	USPAT	OR	ON	2006/03/28 17:33
S18	14	("2001/0054709").URPN.	USPAT	OR	ON	2006/03/28 17:34
S19	257	nanowires and oxidation and etch	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/29 05:55
S20	25	"5607876"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/29 08:31
S21	14	(@ad<="20021118") and nanowires and semiconductor and dispersion and vibration	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/29 09:58
S22	65	(@ad<="20021118") and nanowires and semiconductor and dispersion and (vibrat\$4 or ultrasonic or ultra or remov\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/29 10:03
S23	24	(@ad<="20021118") and nanowires and semiconductor and dispersion and (vibrat\$4 or ultrasonic or ultra)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/29 11:11
S24	27	(@ad<="20021118") and nanowires and sol-gel	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/29 13:39